L	Hits	Search Text	DB	Time stamp
Number 38	9	((430/296).CCLS.) and (nano\$lithograph\$4)	USPAT;	2004/09/14
			US-PGPUB;	15:36
			EPO; JPO;	
			DERWENT	
39	522	Nano\$lithograph\$4 or nanolithograph\$4 or	USPAT;	2004/09/14
		(nano near lithograph\$4)	US-PGPUB;	16:09
	,		EPO; JPO;	
			DERWENT	
40	11	(Nano\$lithograph\$4 or nanolithograph\$4 or	USPAT;	2004/09/14
	,	(nano near lithograph\$4)) and (chemical	US-PGPUB;	16:04
		with functionalization)	EPO; JPO;	
			DERWENT	
41	1989	(430/296).CCLS.	USPAT;	2004/09/14
			US-PGPUB;	15:41
	ı.		EPO; JPO;	
•			DERWENT;	
			IBM_TDB	
42	4	((430/296).CCLS.) and (chemical with	USPAT;	2004/09/14
		functionalization)	US-PGPUB;	15:49
		, and the same of	EPO; JPO;	
	ļ		DERWENT	
44	630	((430/5).CCLS.) and (SAM or mono\$layer or	USPAT;	2004/09/14
44	030	multi\$layer)	US-PGPUB;	15:45
	ļ		EPO; JPO;	
			DERWENT	
43	17	((430/296).CCLS.) and (scanning adj probe)	USPAT;	2004/09/14
			US-PGPUB;	15:45
			EPO; JPO;	
			DERWENT	
		(UADO(E) OOL C) and (SAM or mono\$layer of	USPAT;	2004/09/14
45	0	(((430/5).CCLS.) and (SAM or mono\$layer or	US-PGPUB;	15:49
		multi\$layer)) and (chemical with	EPO; JPO;	
		functionalization)	DERWENT	
			USPAT;	2004/09/14
46	37		US-PGPUB;	16:11
		mono\$layer or multi\$layer)) and (chemical	'	10.11
	1	near (bond or function\$9))	EPO; JPO;	•
			DERWENT	2004/00/44
47	19	"	USPAT;	2004/09/14
		monolyaer)))	US-PGPUB;	16:02
			EPO; JPO;	
			DERWENT	0004/00/44
48	0		USPAT;	2004/09/14
		monolayer)	US-PGPUB;	16:04
			EPO; JPO;	
			DERWENT	
49	O	\$2nitrobenzylsulfides and (chemical with	USPAT;	2004/09/14
		functional\$10)	US-PGPUB;	16:05
			EPO; JPO;	
			DERWENT	

50	0	\$2nitrobenzylsulfides	USPAT;	2004/09/14
			US-PGPUB;	16:05
			EPO; JPO;	
			DERWENT	
51	7	nitrobenzylsulfides	USPAT;	2004/09/14
			US-PGPUB;	16:08
			EPO; JPO;	
			DERWENT	
52	1358	(427/402).CCLS.	USPAT;	2004/09/14
		•	US-PGPUB;	16:09
			EPO; JPO;	
			DERWENT;	
		A	IBM_TDB	
53	5	((427/402).CCLS.) and (Nano\$lithograph\$4 or	USPAT;	2004/09/14
		nanolithograph\$4 or (nano near	US-PGPUB;	16:09
		lithograph\$4))	EPO; JPO;	
			DERWENT	
54	16	((427/402).CCLS.) and (SAM or mono\$layer	USPAT;	2004/09/14
		or multi\$layer) and (chemical near (bond or	US-PGPUB;	16:12
		function\$9))	EPO; JPO;	
			DERWENT	
-	64	"4945028" or "5514501" or "5580697" or	USPAT;	2004/01/06
		"6114099" or "6436615"	US-PGPUB;	15:36
			EPO; JPO;	
	Ì		DERWENT	
-	2	(Nano\$lithography) and (chemical with	USPAT;	2004/09/14
	_	functionalization)	US-PGPUB;	15:41
		,	EPO; JPO;	
			DERWENT	
-	264	Nano\$lithography	USPAT;	2004/09/14
			US-PGPUB;	15:36
			EPO; JPO;	
			DERWENT	